



IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In re application of: Turner, et al.

Attorney Docket No.: NOVLP074/NVLS-000414

Application No.: 09/998,993

Examiner: Maldonado, Julio J.

Filed: November 15, 2001

Group: 2823

Title: PHOSPHOROUS-DOPED SILICON  
DIOXIDE PROCESS TO CUSTOMIZE  
CONTACT ETCH PROFILES

**CERTIFICATE OF EXPRESS MAILING**

I hereby certify that this paper and the documents and/or fees referred to as attached therein are being deposited with the United States Postal Service on August 5, 2004 in an envelope as "Express Mail Post Office to Addressee" service under 37 CFR §1.10, Mailing Label Number **EV334019622US**, addressed to the Commissioner for Patents, P.O. Box 1450, Alexandria, VA 22313-1450.

Signed: \_\_\_\_\_

Jeffrey Ng

**AMENDMENT TRANSMITTAL**

Mail Stop Amendment  
Commissioner for Patents  
P.O. Box 1450  
Alexandria, VA 22313-1450

Sir:

Transmitted herewith is an Amendment in the above-identified application.  
The fee has been calculated as shown below.

	Claims After Amendment		Highest Previously Paid For	Present Extra	Small Entity Rate Fee	Large Entity Rate Fee
Total Claims	25	MINUS	25	0	x 9 =	x 18 = 0
Independent Claims	5	MINUS	5	0	x 43 =	x 86 = 0
Total					\$	\$0

- ☒ Applicant(s) believe that no (additional) Extension of Time is required; however, if it is determined that such an extension is required, Applicant(s) hereby petition that such an extension be granted and authorize the Commissioner to charge the required fees for an Extension of Time under 37 CFR 1.136 to Deposit Account No. 500388.
- ☒ Enclosed is our Check No. 9467 in the amount of \$770.00 to cover the RCE filing fee.
- ☒ Please charge any additional fees required to facilitate filing the enclosed response, to Deposit Account No. 500388 (Order No. NOVLP074).

Respectfully submitted,  
**BEYER WEAVER & THOMAS, LLP**  
Roger J. Sampson  
Reg. No. 44,314

P.O. Box 778  
Berkeley, CA 94704-0778



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Signed: \_\_\_\_\_

Jeffrey Ng

**RESPONSE D**

Mail Stop RCE  
Commissioner for Patents  
P.O. Box 1450  
Alexandria, VA 22313-1450

Dear Sir:

This paper is submitted in response to the Advisory Action dated June 24, 2004 ("Office Action").

**Amendments to the Claims** begin on page 2 of this paper.

**Remarks/Arguments** begin on page 7 of this paper.